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	•	Application	No.	Applicant(s)		
•• ••	Notice of Allowability	10/042,673 Examiner		DANG ET AL. Art Unit		
		Khiem D Ngu	yen	2823		
The MAILING DATE of this communication appears on the cover sheet with the correspondence addressAll claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.						
1.						
	<ul><li>2. \( \sum \) The allowed claim(\$) is/are 1-20.</li><li>3. \( \sum \) The drawings filed on 08 January 2002 are accepted by the Examiner.</li></ul>					
4.						
	1. Certified copies of the priority documents have been received.					
	2. Certified copies of the priority documents have been received in Application No					
	3. Copies of the certified copies of the priority documents have been received in this national stage application from the					
	International Bureau (PCT Rule 17.2(a)).					
* Certified copies not received:						
5. Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
(a) The translation of the foreign language provisional application has been received.						
<b>b</b> . L	Acknowledgment is made of a claim for domestic priority u	under 35 U.S.C.	§§ 120 and/or 121.		-	
App belo	licant has THREE MONTHS FROM THE "MAILING DATE" of w. Failure to timely comply will result in ABANDONMENT of	of this communic f this application	cation to file a reply co . THIS THREE-MON	omplying with the requi	rements noted	
7. [ INF	A SUBSTITUTE OATH OR DECLARATION must be subj DRMAL PATENT APPLICATION (PTO-152) which gives rea	mitted. Note the son(s) why the	attached EXAMINER	'S AMENDMENT or N deficient.	IOTICE OF	
8. 🗀	CORRECTED DRAWINGS must be submitted.  (a) ☐ including changes required by the Notice of Draftspe  1) ☐ hereto or 2) ☐ to Paper No	rson's Patent D	awing Review ( PTO	948) attached		
	(b) including changes required by the proposed drawing correction filed, which has been approved by the Examiner.					
	(c) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No					
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet.						
9. [ atta	DEPOSIT OF and/or INFORMATION about the depondent Examiner's comment regarding REQUIREMENT FOR	osit of BIOLOG THE DEPOSIT	GICAL MATERIAL 11 OF BIOLOGICAL MA	nust be submitted. N TERIAL.	lote the	
Atta	chment(s)					
3⊠ 5⊠	Notice of References Cited (PTO-892) Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449), Paper No. 1 Examiner's Comment Regarding Requirement for Deposit	<u>1003</u> .	4□ Interview Summa 6□ Examiner's Ame	al Patent Application (F ary (PTO-413), Paper I ndment/Comment ement of Reasons for A	No	

U.S. Patent and Trademark Office PTO-37 (Rev. 04-03)

of Biological Material

9 Other

Application/Control Number: 10/042,673

Art Unit: 2823

## **DETAILED ACTION**

## Allowable Subject Matter

Claims 1-20 are allowed.

## Reasons For Allowance

The following is a statement of reasons for the indication of allowable subject matter: The prior art taken alone or in combination neither discloses nor makes obvious the instant process of claims as a whole. Specifically, the prior art of record, Hsu et al. (U.S. Pub. 2002/0191349) discloses a method for forming an electromagnetic transducer comprising (paragraphs [0057]-[0065] and FIG. 10A) forming a first soft magnetic pole layer (FIG. 10A, 82/92) having a substantially flat surface; forming an inorganic nonferromagnetic layer (FIG. 10A, 210) (alumina Al<sub>2</sub>O<sub>3</sub>) and a hardbaked photoresist mask (FIG. 10A, 208) over the first pole layer; and etching the hardbaked photoresist mask and the inorganic nonferromagnetic layer to create an inorganic nonferromagnetic apex region (paragraph [0071] and FIG. 10A) but fails to teach or suggest the Applicant's steps of wherein forming the inorganic nonferromagnetic apex includes forming a photoresist mask over the first pole layer, the mask terminating adjacent to a desired location of the second side, and removing the mask to define the inorganic nonferromagnetic apex as recited in the currently amended independent claims.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Khiem D Nguyen whose telephone number is (703) 306-0210. The examiner can normally be reached on Monday-Friday (8:00 AM - 5:00 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on (703) 306-2794. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 305-3432 for regular communications and (703) 305-3432 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

K.N. January 21, 2004

MILLIAM DAVID COLEMAN Primary Examiner